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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/649,599	08/26/2003	Jack Y. Jau	021773-000310US	4963	
20350 75	590 06/10/2004		EXAM	EXAMINER	
	AND TOWNSEND AN	HUGHES, JAMES P			
TWO EMBARG	CADERO CENTER		ART UNIT	PAPER NUMBER	
	SCO, CA 94111-3834		2881		
			DATE MAIL ED: 06/10/200	4	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	*****	
	10/649,599	JAU ET AL.	JAU ET AL.	
Office Action Summary	Examiner	Art Unit		
	James P. Hughes	2881	AV	
Th MAILING DATE of this communication Period for Reply	n appears on the cover sheet w	ith the correspondence addr	ress	
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICAT - Extensions of time may be available under the provisions of 37 of after SIX (6) MONTHS from the mailing date of this communicati - If the period for reply specified above is less than thirty (30) days - If NO period for reply is specified above, the maximum statutory - Failure to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	ON. FR 1.136(a). In no event, however, may a ron. a reply within the statutory minimum of thir period will apply and will expire SIX (6) MON statute, cause the application to become A	reply be timely filed ty (30) days will be considered timely. ITHS from the mailing date of this com BANDONED (35 U.S.C. § 133).	munication.	
Status				
1) Responsive to communication(s) filed on	the application filed on Eeb. 2	2004		
	This action is non-final.	<u>2004</u> .		
3) Since this application is in condition for al closed in accordance with the practice un	llowance except for formal mat	·	nerits is	
Disposition of Claims				
4) ☐ Claim(s) 13-24 and 36-43 is/are pending 4a) Of the above claim(s) is/are wif 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 13-24 and 36-43 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and subj	thdrawn from consideration.			
Application Papers				
9) ☐ The specification is objected to by the Exa 10) ☑ The drawing(s) filed on 26 August 2003 is Applicant may not request that any objection to Replacement drawing sheet(s) including the color of	dare: a)⊠ accepted or b)⊡ ob to the drawing(s) be held in abeyal correction is required if the drawing	nce. See 37 CFR 1.85(a). (s) is objected to. See 37 CFR		
Priority under 35 U.S.C. § 119				
12) Acknowledgment is made of a claim for for a) All b) Some * c) None of: 1. Certified copies of the priority docu 2. Certified copies of the priority docu 3. Copies of the certified copies of the application from the International B * See the attached detailed Office action for	ments have been received. ments have been received in A e priority documents have been Bureau (PCT Rule 17.2(a)).	Application No received in this National S	tage	
Attachment(s) 1) ☑ Notice of References Cited (PTO-892) 2) ☑ Notice of Draftsperson's Patent Drawing Review (PTO-94 3) ☑ Information Disclosure Statement(s) (PTO-1449 or PTO/5 Paper No(s)/Mail Date 082603.	18) Paper No(Summary (PTO-413) s)/Mail Date nformal Patent Application (PTO-1	152)	

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DETAILED ACTION

Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

1. Claims 13-24 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-12 of U. S. Patent No. 6,710,342.

Although the conflicting claims are not identical, they are not patentably distinct from each other because both the patent and the instant application disclose a method and apparatus for scanning an electron beam at angles that are neither parallel, nor perpendicular, to the orientation of a specimen. Claim 1 of the '342 patent recites a method for scanning the surface of a specimen, using a scanning electron microscope comprising; generating a particle beam from a particle beam source; and scanning the surface of the specimen by deflection the particle beam at an angle with respect to the orientation of the surface features of the specimen such that the particle beam traverses an angle that is neither parallel nor perpendicular to the orientation of the surface features of the specimen. Claim 1 of the instant application recites the corresponding apparatus

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to this method. It would have been obvious to one of ordinary skill in the art at the time of the invention to employ an apparatus to perform the method of the '342 patent because an apparatus is needed to perform this method. Claims 14-24 are similarly rejected because claims 2-12 of the '342 patent teach corresponding methods of the recited apparatus limitations of claims 14-24.

2. Claims 36-43 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 34 and 36 of U.S. Patent No. 6,392,231 in view of claims 13-23 of U.S. Patent No. 6,710,342. In general, claim 36 (in combination with its parent claim 34) of U.S. Patent No. 6,392,231 (hereinafter referred to as the '231 patent) claims the scanning electron microscope of claims 36 and 43 in the instant application; and claims 13-23 of U.S. Patent No. 6,710,342 (hereinafter referred to as the '342 patent) claims a method of scanning the surface of a semiconductor wafer using a scanning electron microscope recited in claims 36-43 of the instant application.

Claim 36 (in combination with its parent claim 34) of the '231 patent claims a scanning microscope for viewing a specimen comprising; a magnetic lens for generating a magnetic field in the vicinity of the specimen to focus the electrons of the electron beam source on the specimen, the magnetic lens having a central bore through which the particle beam travels; an electrode having a potential for providing a retarding field to the particle beam near and at the specimen to reduce the energy of the particle beam when the beam collides with the specimen, a deflection system including a plurality of deflection units situated along the beam axis for deflecting the particle beam to allow scanning of the specimen, at least one of the deflection

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units located in the retarding field of the beam, the remainder of the deflection units located within the central bore of the magnetic lens. (See Col. 12, 11, 7-30)

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However, the '231 patent claims do not teach the deflection system operative to scan the surface of the specimen by bending the particle beam at an angle relative to the orientation of the specimen, such that the particle beam traverses an angle that is not parallel of perpendicular to the orientation or the specimen; or the specific angles at which the particle beam may be scanned.

Claim 13 of the '342 patent claims a method of scanning the surface of a semiconductor wafer using a scanning electron microscope, the method comprising; scanning the surface of the specimen by deflecting the particle beam at an angle with respect to the die orientation of the semiconductor wafer such that the particle beam traverses an angle that is not parallel or perpendicular to the die orientation of the semiconductor wafer. (See e.g., Col. 7, Il. 10-25) Additionally, claim 14 of the '342 patent teaches the beam's response to an appropriate voltage potential (Col. 7, Il. 25-30) and claims 15-23 teach various scanning angles.

It would have been obvious to one of ordinary skill in the art at the time of the invention to adjust the apparatus of claims 34-36 of the '231 patent to perform the method of claims 13-23 of the '342 patent because the scanning method of the '342 method provides an efficient means for imaging a specimen – or semiconductor wafer.

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Conclusion

3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Berkowitz (4,449,051) teaches a method for ion implantation dose control. (Abstract)

Any inquiry concerning this communication or earlier communications from the examiner should be directed to James P. Hughes whose telephone number is 571-272-2474. The examiner can normally be reached on Monday - Friday 9am - 5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John R. Lee can be reached on 571-272-2477. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

James P. Hughes Patent Examiner Art Unit 2881

JH

Mulifa Wells

NIKITA WELLS

PRIMARY EXAMINER 06/01/04